# EL2-like defects in InP nanowires: An ab initio total energy investigation

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We have performed an *ab initio* total energy investigation, within the density-functional theory, of antisite defects in InP nanowires (InP NWs) grown along the [111] direction. Our total energy results indicate that (i) P antisites ( $P_{In}$ ) are the most likely antisite defect compared with In antisites ( $In_P$ ) and (ii) the formation energies of P and In antisites do not depend on the NW diameter. In particular, in thin InP NWs, with diameters of ~13 Å, the  $P_{In}$  antisite exhibits a trigonal symmetry, lying at 0.15 Å from the  $T_d$  site, followed by a metastable configuration with  $P_{In}$  in an interstitial position (1.15 Å from the  $T_d$  site). We find a  $P_{In}$ -P dissociation energy of 0.33 eV, and there is no EL2-like center for such a thin InP NW. However, EL2-like defects occur by increasing the NW diameter. For diameters of ~18 Å, the  $P_{In}$ -P dissociation energy increases to 0.53 eV, which is 0.34 eV lower compared with the  $P_{In}$ -P dissociation energy for the InP bulk phase, 0.87 eV. We mapped the atomic displacements and calculated the relaxation energy, Franck-Condon shift, upon single excitation of  $P_{In}$  induced states in InP NW. The formation (or not) of EL2-like defects,  $P_{In}$  dissociation energy barrier, and the Franck-Condon energy shift can be tuned by the NW diameter.

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## I. INTRODUCTION

Antisite is one of the most studied native defect in III-V compounds, for instance, the EL2 center in GaAs. In a seminal work, Kamińska *et al.*<sup>1</sup> established that the EL2 center exhibits a tetrahedral symmetry formed by an isolated As antisite defect (As<sub>Ga</sub>). Afterward, several experimental<sup>2,3</sup> as well as theoretical studies<sup>4–8</sup> have been done aiming to clarify the structural and electronic properties of EL2 in GaAs. After more than ten years of investigations, currently there is a general agreement that the stable EL2 center is ruled by an isolated As<sub>Ga</sub> with a  $T_d$  symmetry, while the metastable configuration (EL2<sup>*M*</sup>) is attributed to the As<sub>Ga</sub> atom displaced along the  $C_{3v}$  axis.

It is well known that the low-temperature growth of other III-V semiconductors, not only GaAs, allows the preparation of highly nonstoichiometric compounds. Indeed, anionantisite defects in InP,  $P_{In}$ , has been identified for the first time unambiguously through the electron paramagnetic resonance technique by Kenedy and Wilsey.<sup>9</sup> Dreszer *et al.*,<sup>10</sup> using Hall, high-pressure far-infrared absorption and optically detected magnetic-resonance measurements (at low temperature), verified that InP has two dominant donor levels associated with phosphorus antisite defects. Further investigations, based on *ab initio* total energy calculations, proposed the formation of  $P_{In}$  antisite clusters in the InP bulk.<sup>11</sup>

The most interesting property on this class of defects is the fact that they also exhibit a clear metastable behavior.<sup>4,12,13</sup> A neutral anion-antisite defect in III-V compounds has a stable fourfold and a metastable threefold interstitial configuration, where the anion antisite is displaced along the  $C_{3v}$  axis,<sup>13</sup> similarly to EL2 and EL2<sup>M</sup> defects observed in GaAs. This center can be photoexcited into a metastable state, from which it returns to the ground state by thermal activation. Thus, a persistent photoconductivity is expected for P<sub>In</sub> at low temperature.

Nowadays the electronic properties of several materials can be tailored throughout the manipulation and/or control of their size in the atomic scale. Within this new class of (nano)structured materials, the semiconductor nanowires (NWs) are attracting a great deal of interest for future applications in several types of nanodevices. In particular, InP nanowires (InP NWs) have been considered as a potential structure for the fabrication of sensors, light-emitting diodes, and field-effect transistors.<sup>14,15</sup> Usually, the vapor-liquidsolid mechanism, with a gold particle seed, has been utilized for the growth of these nanostructures.<sup>16</sup> These materials are quasi-one-dimensional with electrons confined perpendicularly to the NW growth direction. They exhibit interesting electronic and optical properties due to quantum confinement effects, viz., the size dependence of the InP NW band gap.<sup>17,18</sup> Recent ab initio calculations, performed by Li et al.<sup>19</sup> suggested the formation of a stable *DX* center in small GaAs quantum dots, with dot diameter smaller than  $\sim 15$  nm.

It is quite likely that native defects would form during the NW growth process. Therefore, the structural and electronic properties of these defects are important issues to be addressed in order to improve our understanding of native defects in quasi-one-dimensional (quasi-1D) semiconducting NW systems.

In this paper, we carried out an *ab initio* total energy investigation of antisite defects in InP NWs. We find that the formation of EL2-like defects, antisite dissociation energy, and the Franck-Condon (FC) energy are ruled by the NW diameter. On the other hand, the antisite formation energies are insensitive to the NW diameter,  $P_{In}$  antisites being the most likely defect compared with In<sub>P</sub>. At the equilibrium geometry, the  $P_{In}$  atom in thin InP NW (diameter of 13 Å) exhibits an energetically stable trigonal symmetry, followed by a metastable configuration with  $P_{In}$  in an interstitial position, 1.15 Å from the  $T_d$  site. In this case, the  $P_{In}$ -P dissociation energy is 0.33 eV. Increasing the NW diameter (13  $\rightarrow$  18 Å), we find a P<sub>In</sub>-P dissociation energy of 0.53 eV, where P<sub>In</sub> lying on the  $T_d$  site represents the energetically most stable configuration. For the InP bulk phase, the P<sub>In</sub>-P dissociation energy is equal to 0.87 eV. Similar to the bulk phase, P<sub>In</sub> in InP NW induces the formation of localized states within the energy band gap. However, for such a thin NW system, this defect does not exhibit an EL2-like behavior. On the other hand, by increasing the NW diameter, EL2-like defects are expected to occur. Finally, within a constrained density-functional approach,<sup>20</sup> we map the atomic displacements along the InP NW upon single excitation of P<sub>In</sub> induced states and calculate the respective relaxation energy, FC shift.

### **II. THEORETICAL APPROACH**

Our calculations were performed in the framework of the density-functional theory (DFT),<sup>21</sup> within the generalized gradient approximation due to Perdew et al.<sup>22</sup> The electronion interaction was treated by using norm-conserving, ab initio, fully separable pseudopotentials.<sup>23</sup> The Kohn-Sham wave functions were expanded in a combination of pseudoatomic numerical orbitals.<sup>24</sup> A double zeta basis set including polarization functions was employed to describe the valence electrons.<sup>25</sup> The self-consistent total charge density was obtained by using the SIESTA code.<sup>26</sup> The InP NW was modeled within the supercell approach, where the InP bilayers were piled up along the [111] direction with a periodicity length of  $2\sqrt{3}a$  and diameters of 13 and 18 Å (a represents the optimized lattice constant along the [111] direction of InP NW). The NW surface dangling bonds were saturated with hydrogen atoms. A mesh cutoff of 170 Ry was used for the reciprocal-space expansion of the total charge density, and the Brillouin zone was sampled by using one special  $\mathbf{k}$  point. We have verified the convergence of our results with respect to the number and choice of the special k points. All atoms of the nanowire were fully relaxed within a force convergence criterion of 20 meV/Å.

#### **III. RESULTS AND COMMENTS**

Figure 1 presents the atomic structure of the thinnest InP NW, with a diameter of 13 Å and growth along the [111] direction (see top view [Fig. 1(a)] and side view [Fig. 1(b)]) (the hydrogen atoms are not shown). Due to the 1D quantum confinement, perpendicular to the NW growth direction, the energy gap of the InP NW increases compared with the bulk InP (1.0 eV).<sup>18</sup> We find energy gaps of 2.8 and 2.2 eV for NW diameters of 13 and 18 Å, respectively. It is important to take into account that those energy gaps are underestimated, with respect to the experimental measurements, within the DFT approach. Figure 2(a) presents the electronic band structure of the thinnest InP NW for wave vectors parallel to the [111] direction ( $\Gamma L$  direction). At the  $\Gamma$  point, the highest occupied states exhibit an energy split of 0.31 and 0.20 eV  $(a_1+e)$  for NW diameters of 13 and 18 Å, respectively. The valence-band maximum of bulk InP is described by a threefold degenerated  $t_2$  state. Such  $(t_2 \rightarrow a_1 + e)$  energy splitting is

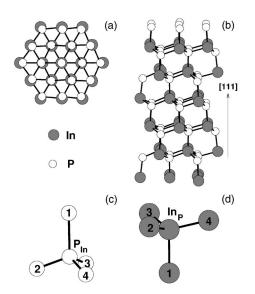


FIG. 1. Structural models of the thinnest InP NW, with a diameter of 13 Å. (a) Top view and (b) side view. The atomic geometry around the antisite defects are indicated in (c)  $P_{In}$  and (d)  $In_{P}$ .

due to the  $T_d \rightarrow C_{3v}$  symmetry lowering of InP NW with respect to the bulk phase.

The energetic stability of antisites in InP NWs can be examined by the calculation of formation energies. The formation energy ( $\Omega_i$ ) of P and In antisites, Figs. 1(c) and 1(d), respectively, can be written as

$$\Omega_i = E(\text{InPNW}_i) - E(\text{InPNW}) - n_{\text{In}}\mu_{\text{In}} - n_{\text{P}}\mu_{\text{P}}.$$

We have considered the formation of antisite inner InP NWs.  $E(\text{InPNW}_i)$  represents the total energy of InP NW, with  $i=P_{\text{In}}$  or In<sub>P</sub> antisite defect, and E(InPNW) is the total energy of a perfect InP NW.  $n_{\text{In}}$  ( $n_{\text{P}}$ ) denotes the number of In (P) atoms in excess or in deficiency. The In and P chemical potentials,  $\mu_{\text{In}}$  and  $\mu_{\text{P}}$ , respectively, are constrained by following the thermodynamic equilibrium condition,  $\mu_{\text{In}} + \mu_{\text{P}} = \mu_{\text{InP}}^{bulk}$ , where  $\mu_{\text{InP}}^{bulk}$  is the chemical potential of bulk InP.

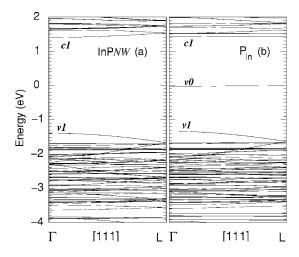


FIG. 2. Electronic band structures of (a) perfect thin InP NW and (b) defective thin InP NW with a P antisite  $(P_{In})$ . NW diameter of 13 Å.

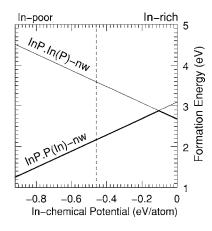


FIG. 3. Formation energies of  $P_{In}$  and  $In_P$  antisites in thin InP NW, with a diameter of 13 Å, as a function of In chemical potential.

Under an In rich (P poor) condition we will have  $\mu_{\text{In}} \rightarrow \mu_{\text{In}}^{bulk}$ , whereas under an In poor (P rich) condition,  $\mu_{\text{In}} \rightarrow \mu_{\text{In}}^{bulk} - \Delta H_f(\text{InP})$ .<sup>27</sup> For the heat of formation of bulk InP,  $\Delta H_f(\text{InP})$ , we have considered its experimental value, 0.92 eV.

Figure 3 presents our calculated results of  $\Omega_i$  for the thinnest InP NW (diameter of 13 Å), as a function of the In chemical potential. It is clear that the formation of P<sub>In</sub> is dominant compared with In<sub>p</sub>. This latter defect occurs only for In rich condition. At the In and P stoichiometric conditions (dashed line in Fig. 3) we obtained  $\Omega_{P_{In}}=2.15$  eV and  $\Omega_{In_p}=3.57$  eV. Increasing the NW diameter (18 Å), we find  $\Omega_{P_{In}}=2.18$  eV. Within the same calculation procedure, we obtained similar formation energy results for the InP bulk phase, viz.,  $\Omega_{P_{In}}=2.14$  eV and  $\Omega_{In_p}=3.59$  eV. These results indicate that (i) there is an energetic preference for P<sub>In</sub> antisites, compared with In<sub>p</sub>, for both NW and bulk phases of InP and (ii) the formation energy of P<sub>In</sub> does not depend on the NW diameter.

At the equilibrium geometry, the P<sub>In</sub> defect in bulk InP keeps the  $T_d$  symmetry with P<sub>In</sub>-P bond lengths of 2.49 Å, while In<sub>P</sub> exhibits a weak Jahn-Teller distortion along the [001] direction. These results are in accordance with previous ab initio studies of antisites in InP.<sup>11,28,29</sup> On the other hand, the equilibrium geometry of antisites in thin InP NW is quite different. The P<sub>In</sub>-P<sub>1</sub> bond, parallel to the NW growth direction, is stretched by 27% compared with the other three  $P_{In}$ - $P_i$  bonds, i=2-4 in Fig. 1(c). Similarly, for the In<sub>P</sub> antisite, In<sub>P</sub>-In<sub>1</sub> is stretched by 8.6% compared with the other three  $In_P$ -In bonds indicated in Fig. 1(d). Figures 4(a) and 4(b) depict the total charge densities along the  $P_{In}$ - $P_1$  and In<sub>P</sub>-In<sub>1</sub> bonds, respectively. In particular, due to the large  $P_{In}$ - $P_1$  bond stretching,  $P_{In}$  is weakly bonded to  $P_1$ , whereas the other  $P_{In}$ - $P_2$ , - $P_3$ , and - $P_4$  bonds [see Fig. 4(a)] exhibit a strong covalent character. Therefore, different from bulk InP,  $P_{In}$  antisites in the NW system exhibit a  $C_{3v}$  symmetry, with the  $P_{In}$  atom displaced from  $T_d$  site by 0.15 Å along the [111] axis. Such a  $P_{In}$  displacement, along the  $C_{3v}$  axis, has not been observed by increasing the NW diameter to 18 Å. In this case, the  $P_{In}$  atom occupies a  $T_d$  site and the  $P_{In}$ -P bond lengths are equal to 2.49 Å.

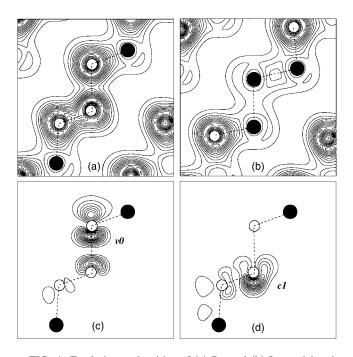


FIG. 4. Total charge densities of (a)  $P_{In}$  and (b)  $In_P$  antisites in InP NW. The partial charge densities of  $P_{In}$  induced (c) highest occupied v0 and (d) lowest unoccupied c1 states.

Several anion-antisite defects in III-V materials were studied by Caldas et al.<sup>13</sup> In that work, based on ab initio total energy calculations, the authors observed an energetically stable  $T_d$  symmetry for P<sub>In</sub> and a metastable  $C_{3v}$  configuration for the antisite atom displaced by  $\sim 1.3$  Å along the [111] direction. Indeed, in Fig. 5(a) we present our total energy results as a function of the P<sub>In</sub> displacement along the [111] direction for the InP bulk phase. We find that the  $T_d$ symmetry represents the energetically most stable configuration, followed by an energy barrier of 0.87 eV at 0.7 Å from the  $T_d$  site, z=0.7 Å, breaking the  $P_{In}-P_1$  bond. Finally, the metastable  $C_{3v}$  configuration occurs for z=1.2 Å, where the  $P_{In}$  occupies an interstitial site. Figures 5(b) and 5(c) present the energy barrier for P<sub>In</sub> in thin InP NW. We have examined two different processes: (i) The In and P atoms of the NW are not allowed to relax during the P<sub>In</sub> displacement [Fig. 5(b)]. (ii) The In and P coordinates are fully relaxed for each  $P_{In}$  step along the [111] direction, i.e., an adiabatic process [Fig. 5(c)]. It is noticeable that the energy barrier calculated in (i) is very similar to that obtained for  $P_{In}$  in bulk InP [Fig. 5(a). In (i), the energetically most stable configuration for  $P_{In}$  exhibits a  $T_d$  symmetry, and we find a dissociation energy of 0.84 eV for z=0.86 Å. Further, P<sub>In</sub> displacement indicates a  $C_{3v}$  metastable geometry for  $z \approx 1.15$  Å, where the P<sub>In</sub> atom occupies an interstitial site. Meanwhile, in (ii) the  $C_{3v}$ symmetry, with the  $P_{In}$  atom lying at 0.15 Å from the  $T_d$ site, represents the energetically most stable configuration. The  $P_{In}$ - $P_1$  dissociation energy reduces to 0.33 eV (at z =0.85 Å), and there is a metastable geometry for z  $\approx 1.15$  Å. The total energy difference between the stable (S) and the metastable (M) configurations, E(S) - E(M), in InP NW is equal to -0.084 eV, while in bulk InP we find E(S)-E(M) = -0.53 eV. Comparing (i) and (ii), we verify that the atomic relaxation plays a fundamental role not only for the

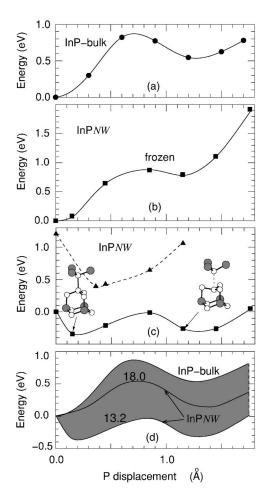


FIG. 5. Total energy as a function of the  $P_{In}$  antisite displacement along the [111] direction: (a) bulk InP and (b) InP NW where the In and P atoms are not allowed to relax during the  $P_{In}$  displacement. (c) Whole In and P atomic positions along the NW are allowed to relax. In (c), the total energy barrier indicated by triangles (dashed line) was calculated for an excited electronic configuration, single excitation. (d) Energy barriers for bulk InP and thin InP NW systems.

energy barrier for the  $P_{In}$  atomic displacement along the [111] direction but also for the equilibrium geometry of the  $P_{In}$  structure. Increasing the NW diameter, the energy barrier for the  $P_{In}$  displacement will become similar to that obtained for bulk InP (an upper limit for a very large NW diameter) [see Fig. 5(d)]. Indeed, for a NW diameter of 18 Å, we find a  $P_{In}$ - $P_1$  dissociation energy of 0.53 eV and E(S)-E(M) equal to -0.14 eV. These results indicate that the  $P_{In}$ - $P_1$  dissociation barrier, and the E(S)-E(M) total energy difference, can be tuned (by the NW diameter) within the shaded region indicated in Fig. 5(d).

Focusing on the electronic structure, the formation of the  $P_{In}$  defect in thin InP NW gives rise to a deep double donor state, labeled v0 in Fig. 2(b), lying at 1.3 eV above v1. Such a  $P_{In}$  induced state is very localized within the fundamental band gap, being almost flat along the  $\Gamma L$  direction. For  $P_{In}$  in bulk InP, *ab initio* studies performed by Seitsonen *et al.*<sup>28</sup> indicates the formation of an occupied state at 0.7 eV above the valence-band maximum. The partial charge-density con-

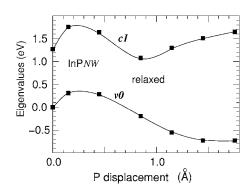


FIG. 6. Single-particle eigenvalues ( $\epsilon$ ) for P<sub>In</sub>: highest occupied v0 [Fig. 4(c)] and lowest unoccupied c1 [Fig. 4(d)].

tour plot of v0 [Fig. 4(c)] shows an antibonding  $\pi^*$  orbital concentrated along the P<sub>In</sub>-P<sub>1</sub> bond. The lowest unoccupied state, c1, is also concentrated on the P<sub>In</sub> antisite, as depicted in Fig. 4(d).

EL2 and EL2<sup>*M*</sup> centers in III-V are characterized by a stable  $T_d$  and a metastable  $C_{3v}$  geometries for an isolated  $V_{III}$  interstitial atom. However, before the  $V_{III}$  antisite arrives at the metastable  $C_{3v}$  configuration, there is a strong electronic coupling between the highest occupied and the lowest unoccupied antisite induced states near the local maximum for the  $V_{III}$ -V dissociation energy (see Fig. 3 in Ref. 13 and Fig. 4 in Ref. 30).

Similarly, for the thin InP NW, we examined the energy positions of single-particle eigenvalues,  $\epsilon(v0)$  and  $\epsilon(c1)$ , as a function of the P<sub>In</sub> displacement along the  $C_{3v}$  axis. Our calculated results, depicted in Fig. 6, reveal that there is no electronic coupling between v0 and c1. Thus, based on the calculated energy barrier [Fig. 5(c)] and the evolution of the antisite induced states, v0 and c1, we can state that there is no EL2-like center in thin InP NWs. On the other hand, increasing the NW diameter [Fig. 5(d)], an EL2-like center is expected to occur in InP.

Within the DFT approach, we have examined the structural relaxations upon single excitation from the highest occupied state (v0) to the lowest unoccupied state (c1) of  $P_{In}$  in thin InP NW. We have used the calculation procedure proposed by Artacho et al., where the single excitation was modeled by "promoting an electron from the highest occupied molecular orbital to the lowest unoccupied molecular orbital,"<sup>20</sup> i.e., a "constrained" DFT calculation. Hence, promoting one electron from v0 to c1,  $v0 \rightarrow c1$ , we obtained the equilibrium geometry (full relaxations) as well as the selfconsistent electronic charge density. The atomic relaxations along the thinnest InP NW, upon  $v0 \rightarrow c1$  single excitation, are localized near the PIn position. Since we are removing one electron from the antibonding  $\pi^*$  orbital depicted in Fig. 4(c), the  $P_{In}$ - $P_1$  bond shrinks by 0.12 Å (2.90 $\rightarrow$  2.78 Å) and there is a radial a contraction of  $\sim 0.2$  Å at z = 6.8 Å.

The structural relaxations are proportional to the degradation of optical energy due to the atomic displacements associated with such a  $v0 \rightarrow c1$  single excitation, FC shift. Comparing the radial and the longitudinal displacements, we verify that most of the FC shifts come from the atomic relaxation parallel to the NW growth direction. The atomic displacements along the radial direction ( $\Delta r$ ) are localized nearby P<sub>In</sub>, lying within an interval of  $-0.2 < \Delta r < 0$  Å, while the atomic displacements parallel to the growth direction ( $\Delta z$ ) lie within a range of  $-0.2 < \Delta z < 0.3$  Å, being less concentrated around the P<sub>In</sub> antisite position. We find a FC energy shift of 0.8 eV, which is quite large compared with the InP bulk phase. Within the same calculation approach, we find a FC energy shift of 0.05 eV for InP bulk. Previous *ab initio* study indicates a FC energy shift of 0.1 eV for bulk InP, suggesting thus that the FC energy shift can also be tuned by controlling the NW diameter.

### **IV. CONCLUSIONS**

In summary, we have performed an *ab initio* total energy investigation of antisites in InP NW. We find that the  $P_{In}$ antisite is the most likely to occur. For thin InP NWs, the  $P_{In}$ atom exhibits a trigonal symmetry, followed by a metastable P interstitial configuration. Increasing the NW diameter (18 Å),  $P_{In}$  occupying the  $T_d$  site becomes the energetically

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most stable configuration. The calculated energy barrier, for  $P_{In}$  displacement along the  $C_{3v}$  axis, indicates that there is no EL2-like defect in thin InP NWs. However, increasing the NW diameter,  $13 \rightarrow 18$  Å, we observe the formation of EL2-like defects in InP. Within a constrained DFT approach, we calculated the structural relaxations and the FC energy shift upon single excitation of the electronic states induced by  $P_{In}$ . We inferred that not only the formation (or not) of EL2-like defects but also (i) the  $P_{In}$ -P dissociation energy, (ii) the total energy difference between stable and metastable  $P_{In}$  configurations, E(S)-E(M), and the (iii) FC energy shift can be tuned by controlling the InP NW diameter.

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